

*DB=EPAB,JPAB,DWPI; PLUR=YES; OP=ADJ*

<input type="checkbox"/>	L8	(wafer or substrate or semiconductor) same (clean\$3 or wash\$3) same gate same (ozon\$5 with water)	10
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*DB=PGPB,USPT,USOC,EPAB,JPAB,DWPI; PLUR=YES; OP=ADJ*

<input type="checkbox"/>	L7	(wafer or substrate or semiconductor) same (clean\$3 or wash\$3) same gate same (ozon\$5 with water)	54
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<input type="checkbox"/>	L6	L5 and ((wafer or substrate or semiconductor) same gate same (ozon\$5 with water))	2
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<input type="checkbox"/>	L5	L4 or l3 or l2 or l1	2280
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<input type="checkbox"/>	L4	(macronix international).as.	1196
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<input type="checkbox"/>	L3	yang-ling\$.in.	41
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<input type="checkbox"/>	L2	chen-cheng\$.in.	629
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<input type="checkbox"/>	L1	huang-chih\$.in.	436
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END OF SEARCH HISTORY

## WEST Search History





DATE: Friday, March 16, 2007

Hide?	<u>Set</u> <u>Name</u>	<u>Query</u>	<u>Hit</u> <u>Count</u>
	<i>DB=PGPB,USPT,USOC; PLUR=YES; OP=ADJ</i>		
<input type="checkbox"/>	L31	L30 and l12	12
<input type="checkbox"/>	L30	l25 and gate	50
<input type="checkbox"/>	L29	l25 same gate	6
	<i>DB=EPAB,JPAB,DWPI; PLUR=YES; OP=ADJ</i>		
<input type="checkbox"/>	L28	L26 and gate	3
<input type="checkbox"/>	L27	L26 same gate	2
<input type="checkbox"/>	L26	(semiconductor or wafer or substrate) same (ozon\$5 with water) same ((SC1 or APM or (ammonium hydroxide) or "NH.sub.4OH"))	30
	<i>DB=PGPB,USPT,USOC; PLUR=YES; OP=ADJ</i>		
<input type="checkbox"/>	L25	(semiconductor or wafer or substrate) same (ozon\$5 with water) same ((SC1 or APM or (ammonium hydroxide) or "NH.sub.4OH"))	145
<input type="checkbox"/>	L24	(gate with oxide) same (clean\$3 or wash\$3) same (ozon\$5 with water)	22
<input type="checkbox"/>	L23	(gate with oxide) same (clean\$3 or wash\$3 or etch\$3) same (ozon\$5 with water)	34
<input type="checkbox"/>	L22	l11 same (SC1 or ammonia or (ammonium hydroxide))	14
	<i>DB=USPT; PLUR=YES; OP=ADJ</i>		
<input type="checkbox"/>	L21	l20 and gate	2
<input type="checkbox"/>	L20	4341592.pn. or 6491763.pn.	2
	<i>DB=PGPB,USPT,USOC; PLUR=YES; OP=ADJ</i>		
<input type="checkbox"/>	L19	l16 and l12	11
<input type="checkbox"/>	L18	L16 and (ozon\$5 with water)	2
<input type="checkbox"/>	L17	L16 same (ozon\$5 with water)	1
<input type="checkbox"/>	L16	L15 same oxide	81
<input type="checkbox"/>	L15	L14 same (clean\$3 or rins\$3 or wash\$3)	96
<input type="checkbox"/>	L14	(wafer or substrate or semiconductor) with(float\$3 adj gate)	13499
<input type="checkbox"/>	L13	L12 and l11	9
<input type="checkbox"/>	L12	134/2,25.4,26,29,30;438/593,585,591,689,723,724,906.ccls.	12219
<input type="checkbox"/>	L11	(wafer or substrate or semiconductor) same (clean\$3 or wash\$3) same gate same (ozon\$5 with water)	44
<input type="checkbox"/>	L10	(wafer or substrate or semiconductor) same (clean\$3 or wash\$3) same (gate with float\$3) same (ozon\$5 with water)	1
<input type="checkbox"/>	L9	(wafer or substrate or semiconductor) same (clean\$3 or wash\$3) same (gate adj5 float\$3) same (ozon\$5 with water)	0